	Docket Number (Optional) FIS920040258US1	Application Number 10/711,700	
DEFORMATION DISCLOSURE CITATION Officers several sheets if necessary) APR 17 1006	Applicant(s) Kevin Petrarca, et al.		
	Filing Date 09/30/04	Group Art Unit 2818	

3	U.S. PATENT DOCUMENTS					
Examiner Cite Initiate No. No.		Document Number Publication Data Number-Kind Code ² (if known)		Name of Patentee or	Pages, Columns, Lines, Where Relevent Passages or Relevent Figures Appear	
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		EP-0952242	11-16-1998	LANDAU, et al.	<u> </u>	J
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		NON PATENT LITERATURE DOCUMENTS	
xaminer nitiels	الملطة	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, manazine, fournal, serial, symposium, catalog, etc.), date, page(s), volume-lesse number(s), publisher, city	T²
MIN	CA**	A Novel Electrolyte Composition for Copper Plating in Wafer Metallization, Electrochamical Processing in ULSI Fabrication and Semiconductor/Metal Deposition II: Proceedings of the Intenational Symposium; P.C.: Uziel LANDAU, et al., The Electrochemical Society, Inc.	
THN	CB**	A Model of Superfilling in Damascene Electropialing, N. OELISUMM, 1999).	-
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THN	CF**	Model of Waler Thickness Uniformity in an Electrocopiating Tool, Electrocommunity in an Electrocopiating Tool, Electrochemist of the International In ULSI Fabrication and Semicondutor/Metal Deposition II: Proceedings of the International Symposium, P.C.H. DELIGIANNI, et al., The Electrochemical Society, Inc., Proceedings	
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esterisk (*) next to the both of the section for an earlier filling date under 35 U.S.C. 120. Examiner Signature	3/1/	Date Considered	07/06/06
Signature WWW - / - V			•